

High-Resolution Transmission Electron Microscopy with Zach Phase Plate

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Introduction

- Physical phase plates (PP) enhance the contrast of weak-phase objects in transmission electron microscopy (TEM) [1].
- Different methods exist to impose the required relative phase shift between scattered and unscattered electrons [2].
- A major disadvantage of the most common thin-film based PPs is the scattering of electrons in the PP itself leading to a phase-contrast damping and a loss of resolution.
- The electrostatic Zach-PP (Fig. 2) induces a variable phase shift on the unscattered electrons in the back focal plane (BFP) of the objective lens (Fig. 1) [3].
- As a damping or a loss of resolution is not expected, this work aims on the **application of the Zach-PP in high-resolution (HR)TEM.**

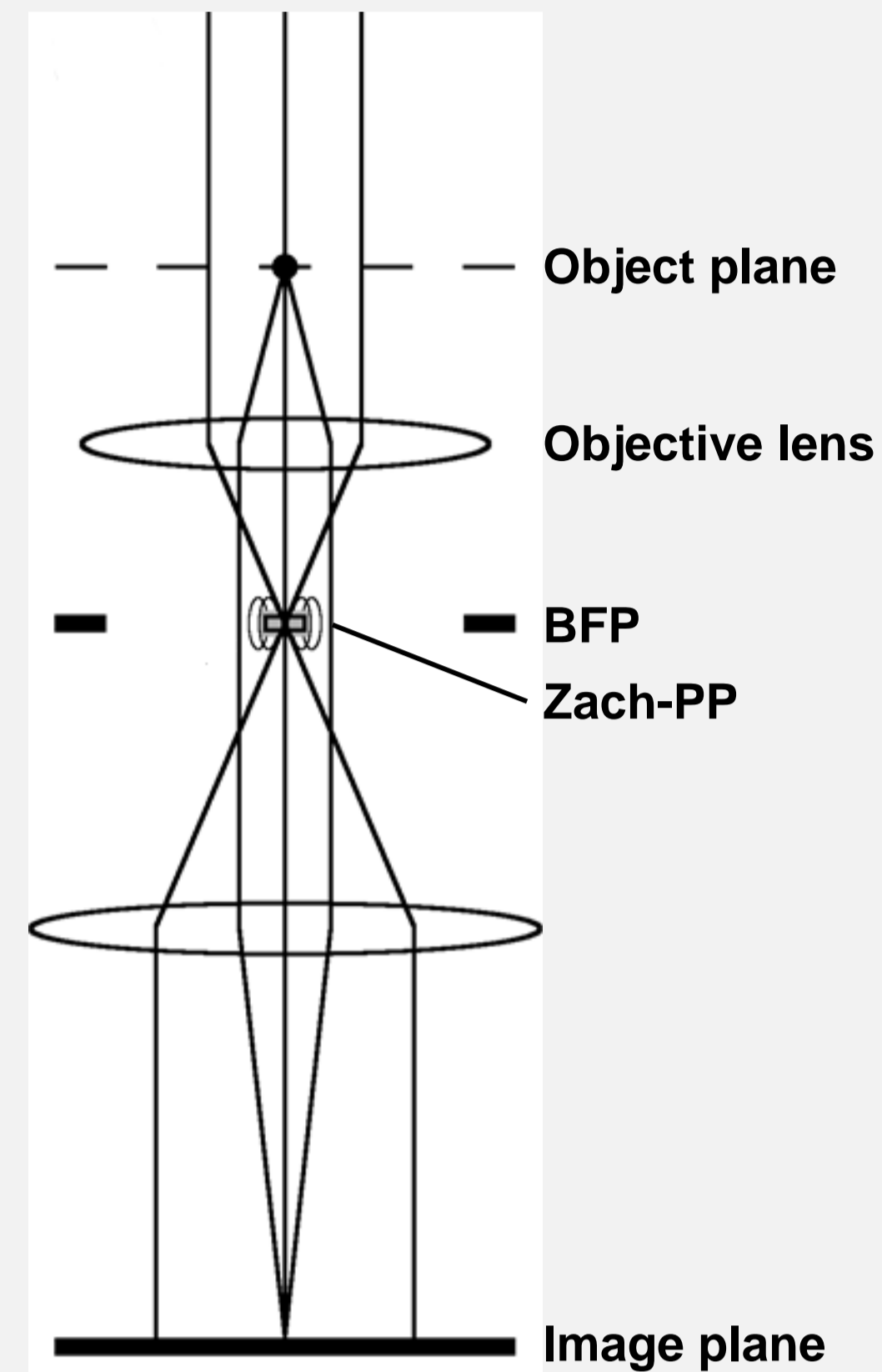


Fig. 1: Schematic illustration of an electrostatic Zach-PP positioned in the BFP of the objective lens.

Application of the Zach-PP

- Visibility of lattice fringes and reflections indicate a negligible phase-contrast damping induced by the Zach-PP (compare Figs. 3 and 4).
- (111) reflections are distinguished by their position with respect to the PP-rod (white): Affected (red) and unaffected (green).

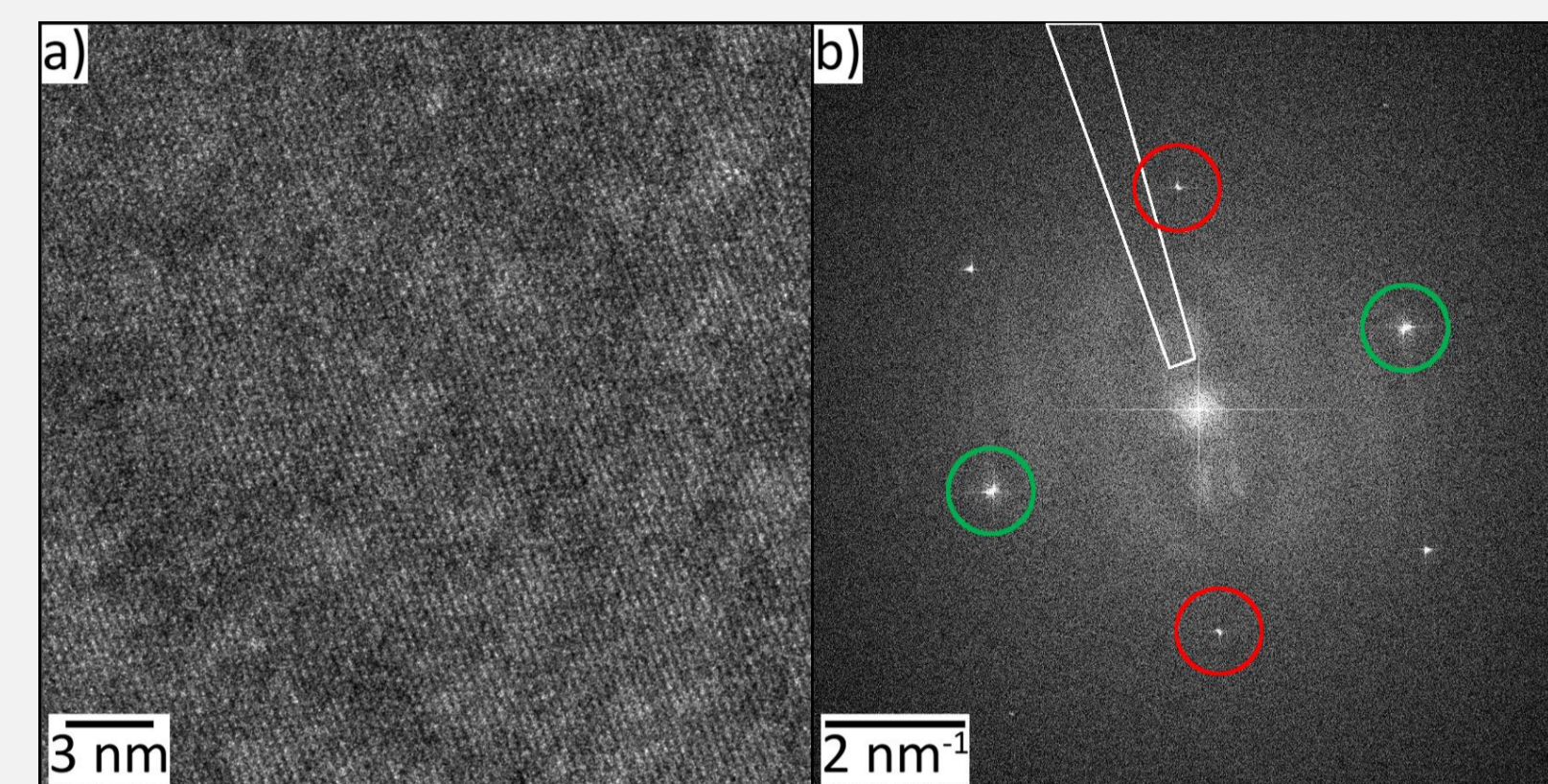


Fig. 4: HRTEM image of the Si single-crystal sample with Zach-PP.

- (a) The visibility of the lattice fringes is an indication that the Zach-PP does not decrease the resolution.
- (b) The corresponding power spectrum shows the marked (111) reflections and the rod of the Zach-PP.

Analysis of the reflection intensity

- Acquisition of a HRTEM image series of the same sample area with different applied voltages and otherwise unchanged conditions.
- A linear dependence of φ_{PP} on the applied voltage is verified by Thon-ring analysis.
- Determination of (111) reflection intensities in Wiener-filtered power spectra (x/+ in Fig. 5).
- Fit to a function with cosinusoidal behavior (Eq. 1) yields a good agreement with the measured data points (Fig. 5).
- Undesired aberrations, charging effects or a deviation from perfect zone-axis orientation hamper the analysis and lead to the observed lower intensity of the (111) reflections affected by the PP rod (red curve in Fig. 5).

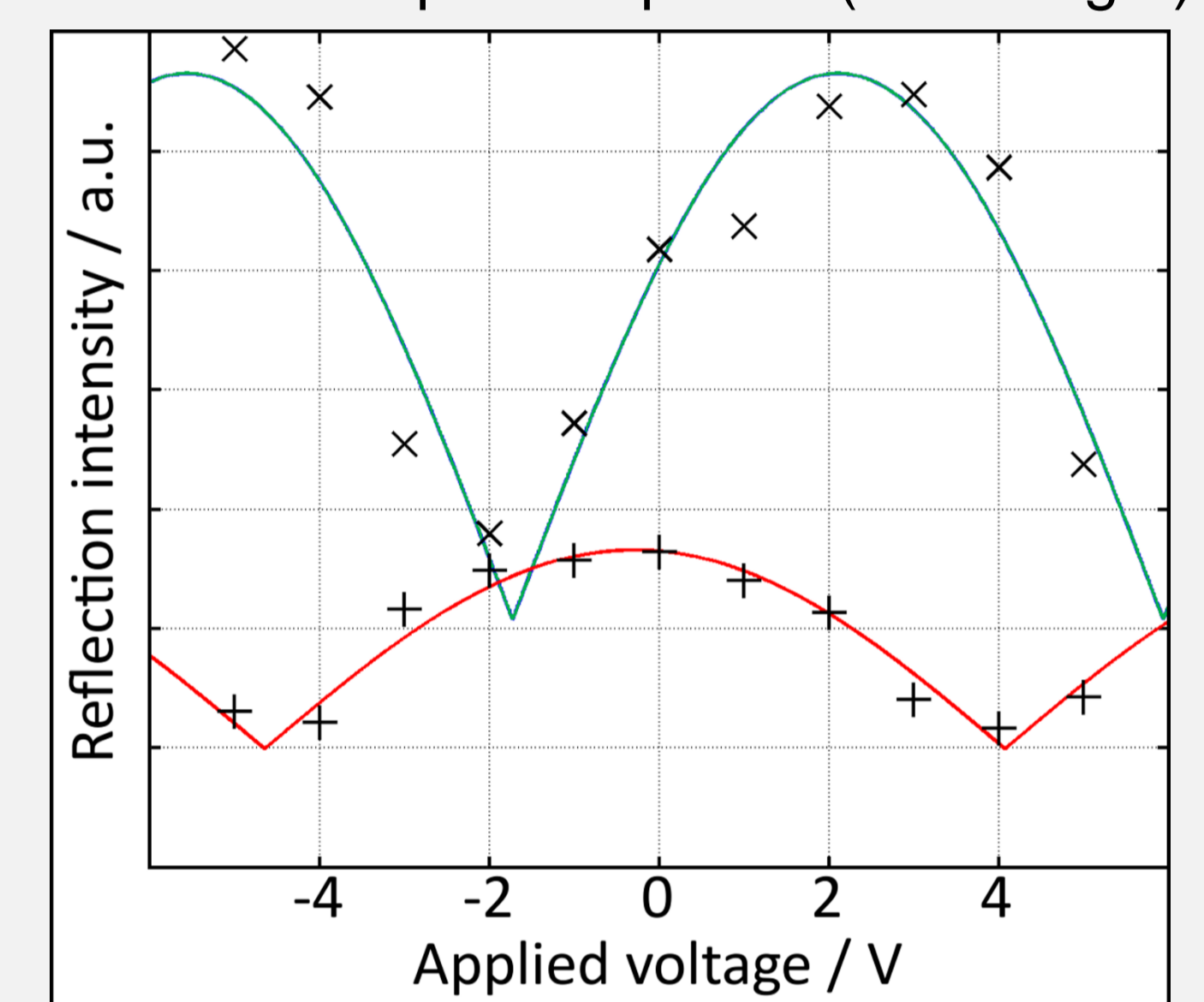


Fig. 5: Analysis of (111) reflection intensities in power spectra acquired with the Zach-PP in dependence of the applied voltage. Good agreement between measurements (x,+) and predicted cosinusoidal dependence (green, red curve).

Design and fabrication of a Zach-PP

- The Zach-PP consists of a single rod carrying a 5-layer system with Au electrode, insulating layers of Si₃N₄ and Al₂O₃ and Au shielding.
- Additional evaporation of amorphous carbon minimizes contamination and electrostatic charging.
- Complex fabrication process needed using electron-beam lithography, physical vapor deposition, reactive ion etching and focused ion beam milling as described in [4].
- Implementation in the BFP of a Zeiss 923Ω transmission electron microscope operated at 200 kV and equipped with a TVIPS CCD camera.

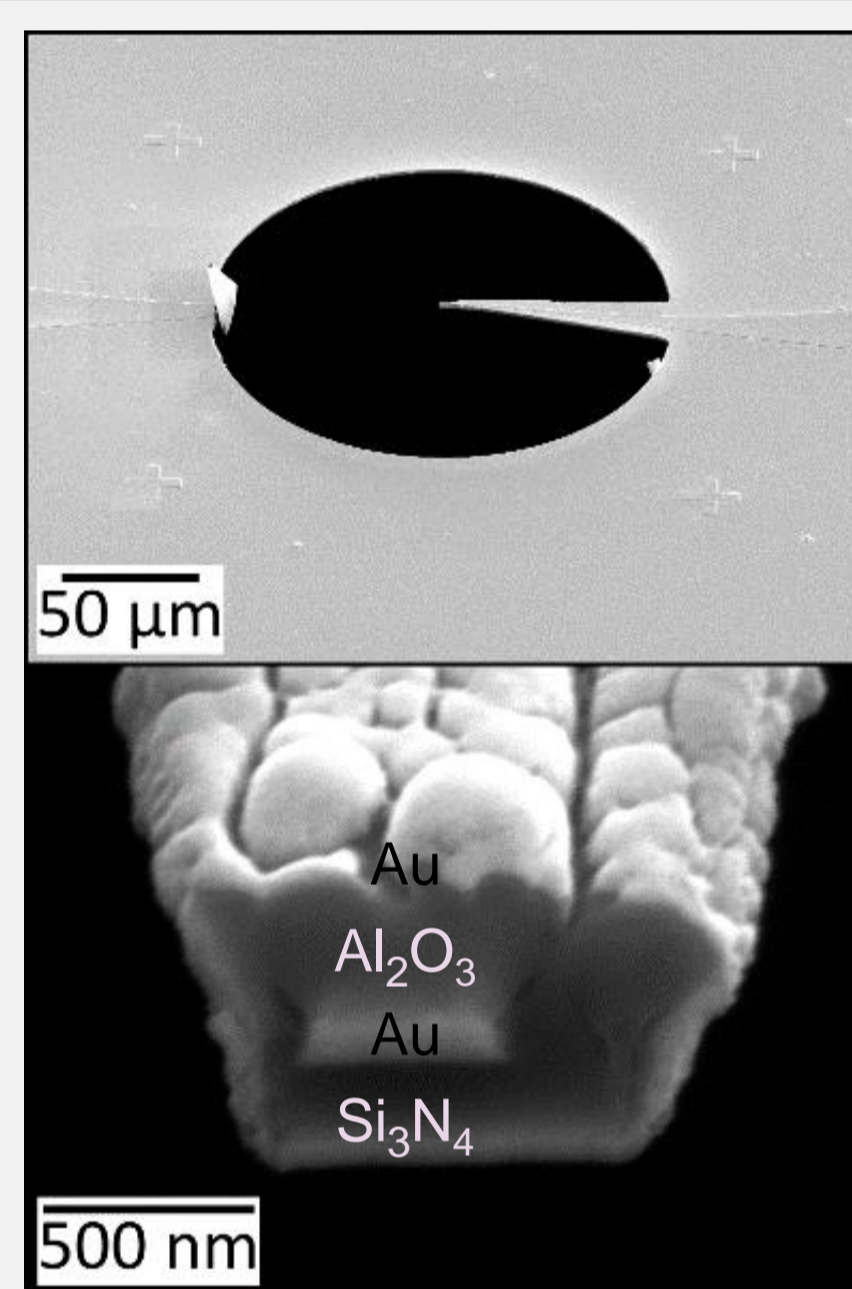


Fig. 2: Scanning electron microscopy images of the electrostatic Zach-PP used for the experiments. The detail image reveals the layer system.

Sample characterization

- Investigation of a Si single-crystal sample in [110] orientation.
- (111)-type lattice fringes and reflections are visible in the HRTEM image (Fig. 3a) and the corresponding power spectrum (Fig. 3b).

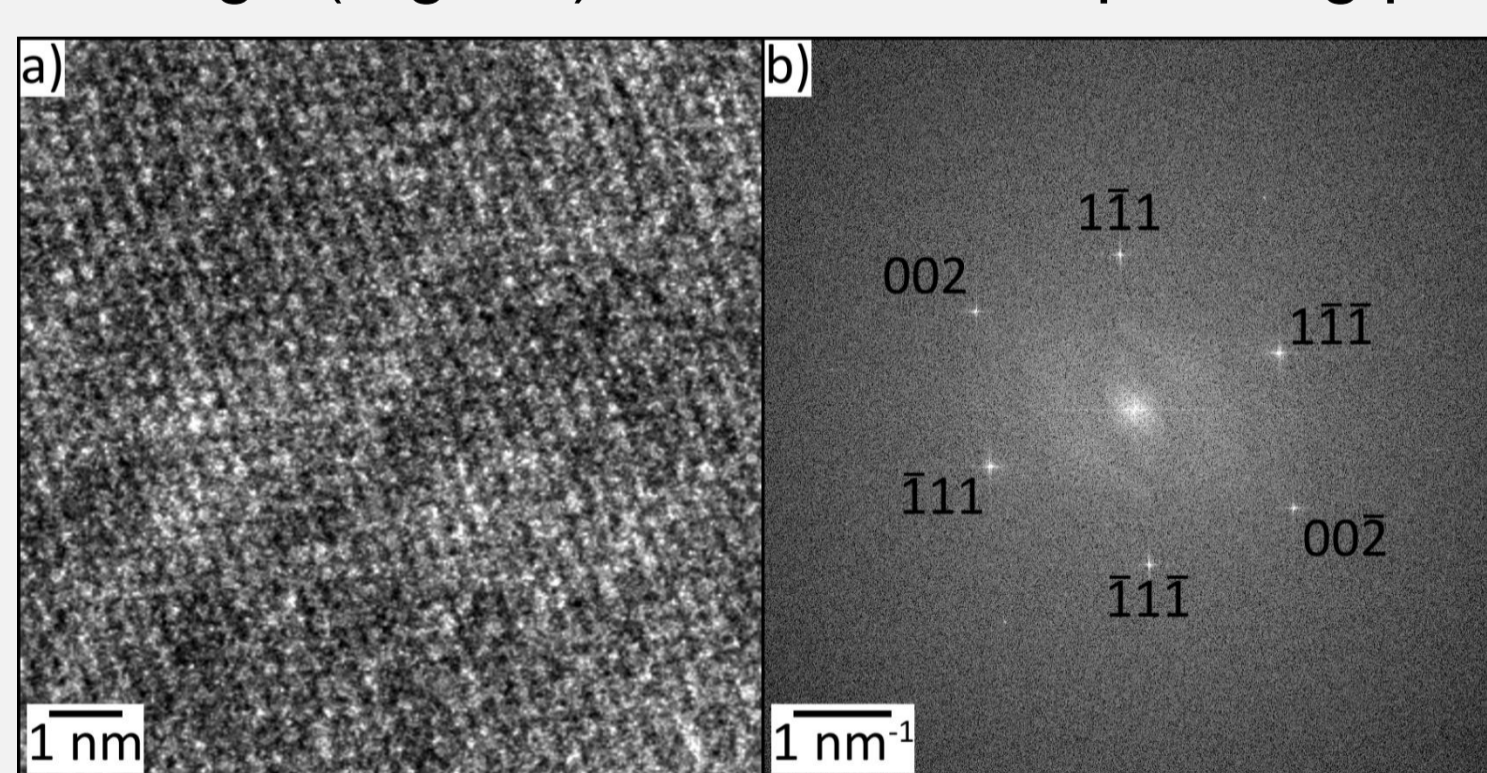


Fig. 3: Characterization of the Si single-crystal sample.

- (a) Plan-view TEM image reveals (111)-type lattice fringes.
- (b) The corresponding power spectrum shows the (111) and (002) reflections.

HRTEM image formation with Zach-PP

- The influence of the Zach-PP on the image formation process in HRTEM is best analyzed by the reflection intensity in power spectra.
- Assuming isotropic conditions, the reflection intensity \tilde{I} shows a cosinusoidal dependence on the induced phase shift φ_{PP} .

$$\tilde{I}(u) \propto 2a_0 a_u E(u) |\cos(\varphi_u - \varphi_0 + \chi - \varphi_{PP})| \quad (\text{Eq. 1})$$

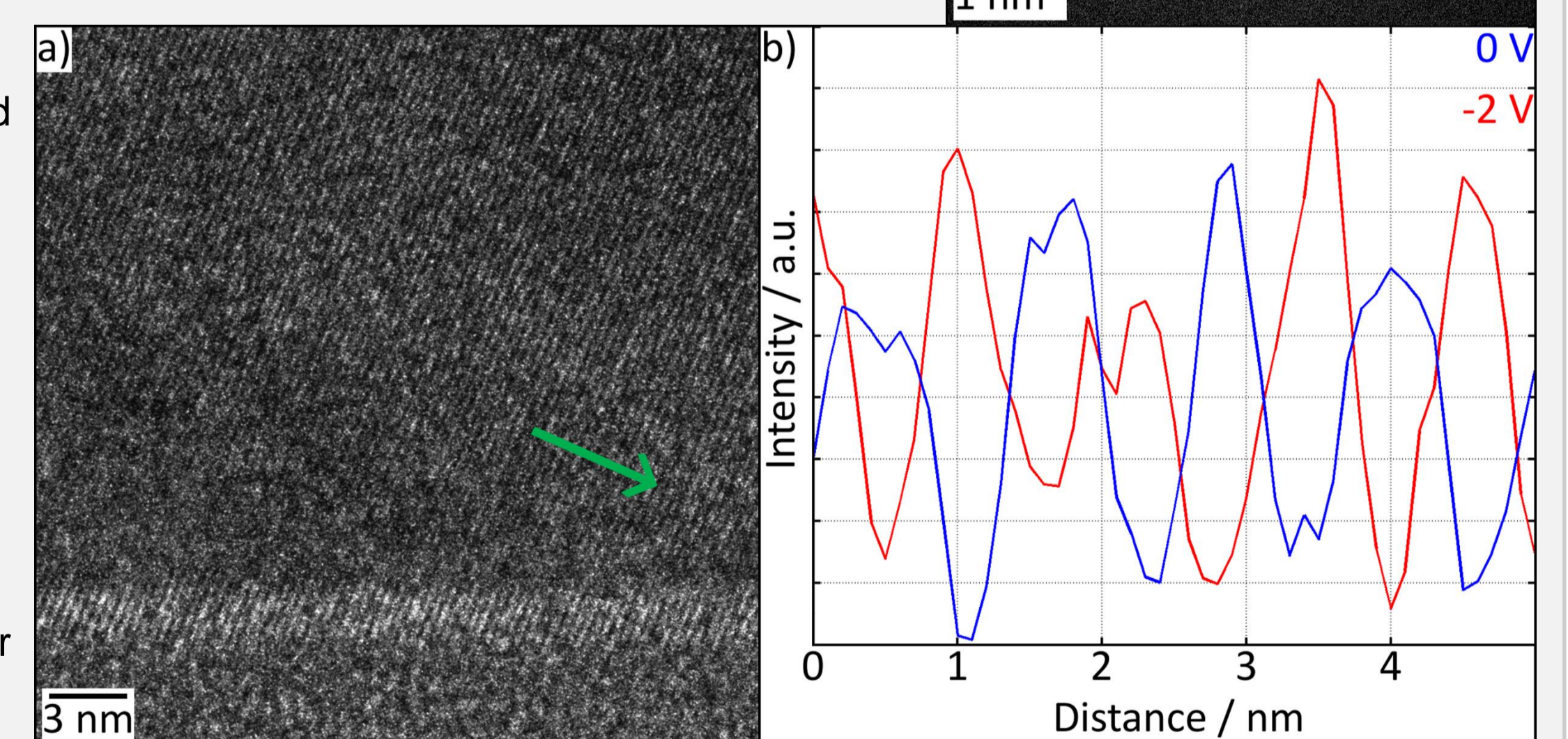
with the envelope function E ; the wave aberration function χ ; the amplitude and phase of the diffracted/undiffracted beam $a_{u/0}$, $\varphi_{u/0}$ and the spatial frequency u .

Phase-contrast inversion in HRTEM images

- If one reflection is blocked by the PP rod, the HRTEM pattern is reduced to a line pattern (Fig. 6a), which is formed by the unaffected reflection pair (marked green in Fig. 6c).
- The remaining (111) reflection pair and the corresponding lattice fringe contrast can be influenced by φ_{PP} .
- The contrast of the lattice fringes can be inverted by applying appropriate PP-voltages, which is shown in the line profile in Fig. 6b taken from manually aligned images.

Fig. 6: Analysis of a HRTEM image with one reflection blocked by the PP.

- (a) HRTEM pattern is reduced to a line pattern.
- (b) Line profile across the green arrow in (a) shows inverted phase contrast for different applied voltages.
- (c) Corresponding power spectrum to (a) shows the unaffected (111) reflection pair marked green.



Summary

- Application of the electrostatic Zach-PP for HRTEM is advantageous.
- Oscillation of the reflection intensity with varying φ_{PP} .
- Phase-contrast inversion of lattice fringes induced by the Zach-PP.
- Good agreement between experiment and theoretical calculations.

Outlook

- The application of the Zach-PP is limited by the capabilities of the microscope. Further investigation in a state-of-the-art microscope could offer:
 - Determination of local information like sample thickness or composition.
 - Quantitative HRTEM by object-wave reconstruction with Zach-PP [5].
 - Improved resolution in single-particle reconstruction.

References

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- [6] Funding of the Deutsche Forschungsgemeinschaft is acknowledged.